

JS301-200 Spin Coater

200 mm Spin Coater

The JS301-200 benchtop series of small substrate spincoaters is designed for versatility, ease of use and safety in a variety of research and development processes. This spincoater is ideal for processes such as the coating and developing of silicon wafers, glasses, large photomasks, reticles.

- Robust structure
- Easy to use
- Repeatable performance
- Flexibility
- Economical benchtop system



Specification

Programmable 3 steps, 3 speeds
Digital RPM meters and timers
Accuracy $\pm 1\%$ at set RPM
Max RPM: 4,500
Acceleration: 3,000RPM/sec.
SUS304 body and bowl
for easy cleaning and chemical resistance
Drain port
Clear PC cover for bowl
Max 200mm diameter & 150x150mm plate
Standard dry vacuum pump: 100 liter/ min, 0.5 ATM
Standard sample chuck
Dimension 500W x 450D x 275H mm
220VAC, 60Hz, 3 amp
Weight: 30 Kg



JAESUNG JS301 SPIN COATING SYSTEM

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SOLUTIONS PROVIDER

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